

# INSULATOR–TO–METAL SWITCH VIA THE FIELD–DRIVEN COLLAPSE OF THE MOTT GAP

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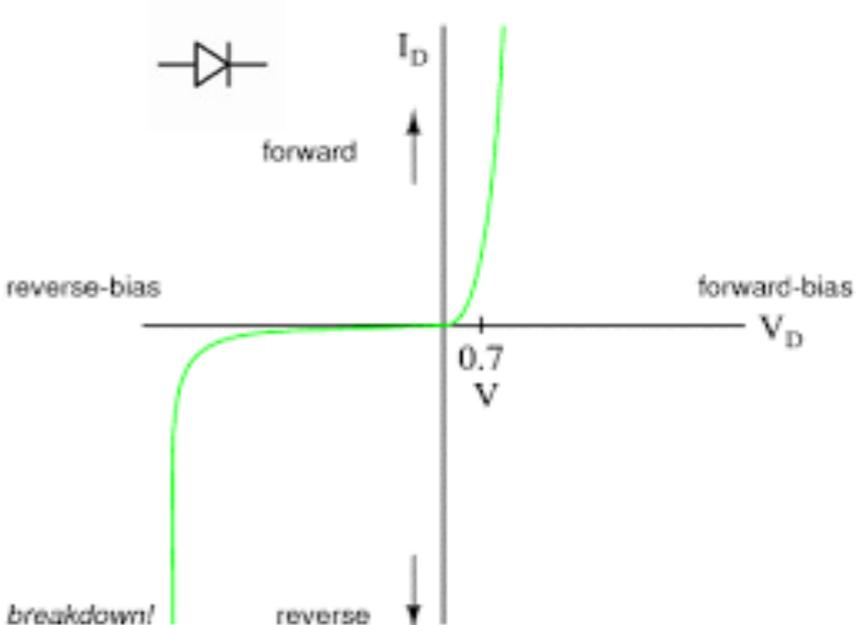
International School for Advanced Studies @ Trieste

**arXiv 1602.03138**

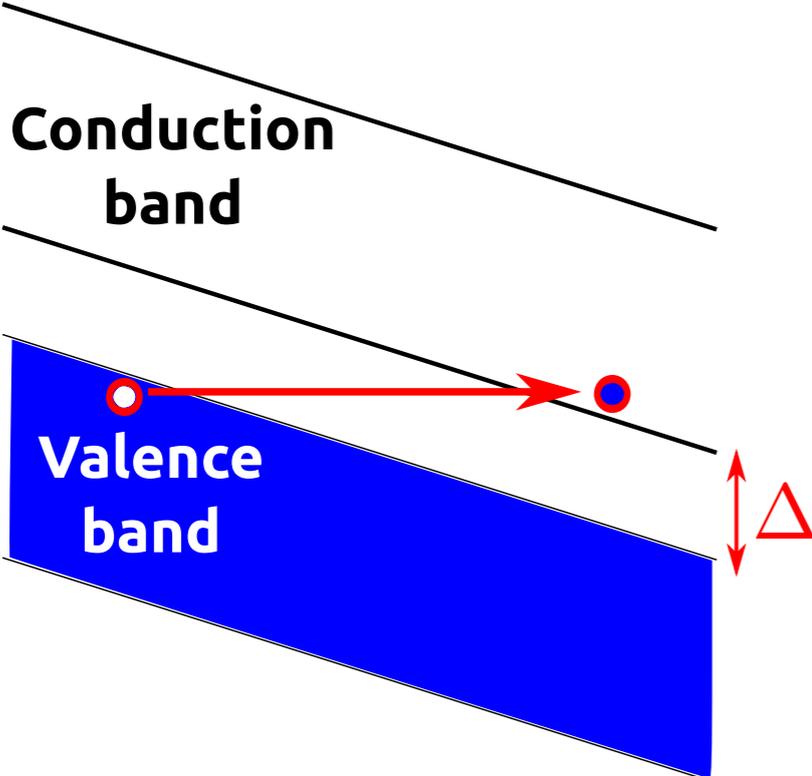
NGSCES 2016, Trieste

# Control of the conductive properties of materials

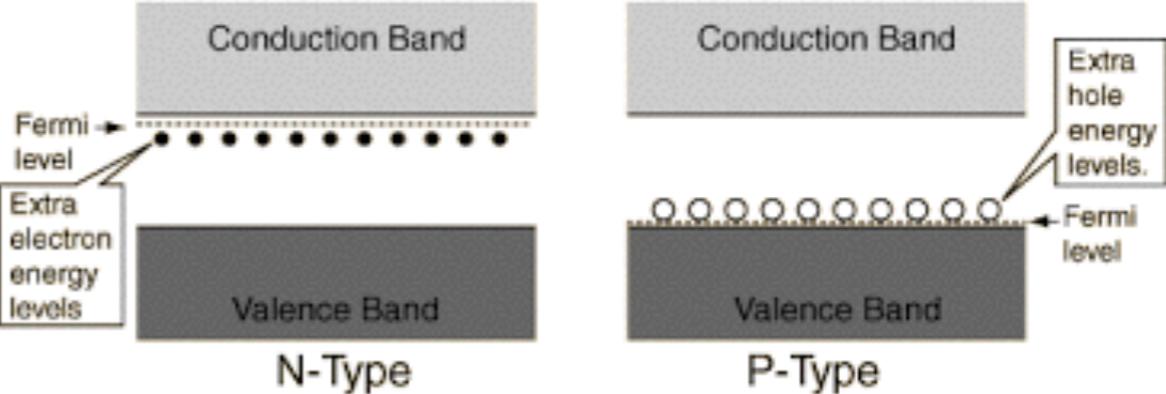
## Semiconductor based electronic devices



\* Quantum tunneling



\* Chemical doping

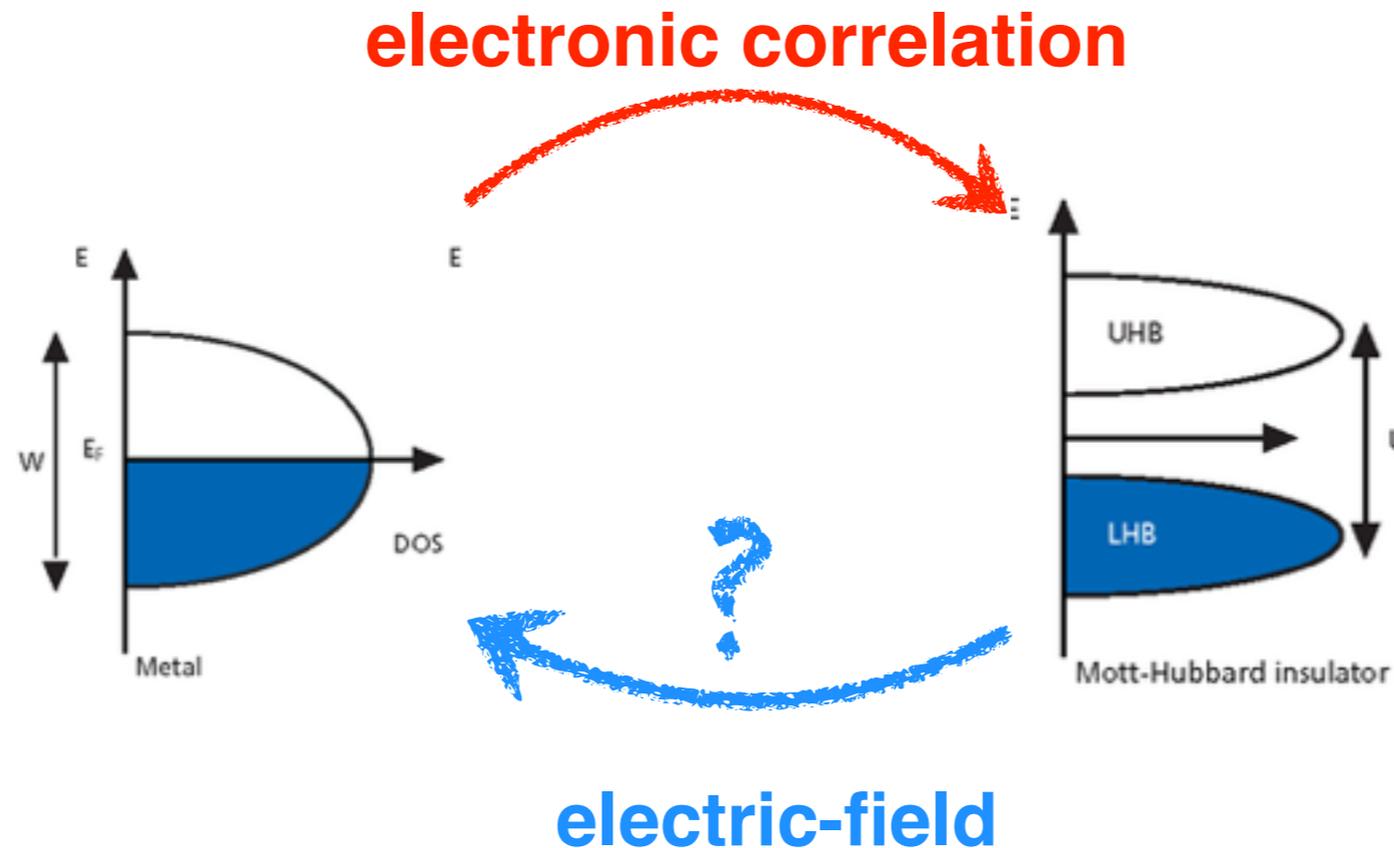


# Why Correlated Materials?

“unsuccessful  
metals”



Mott insulators



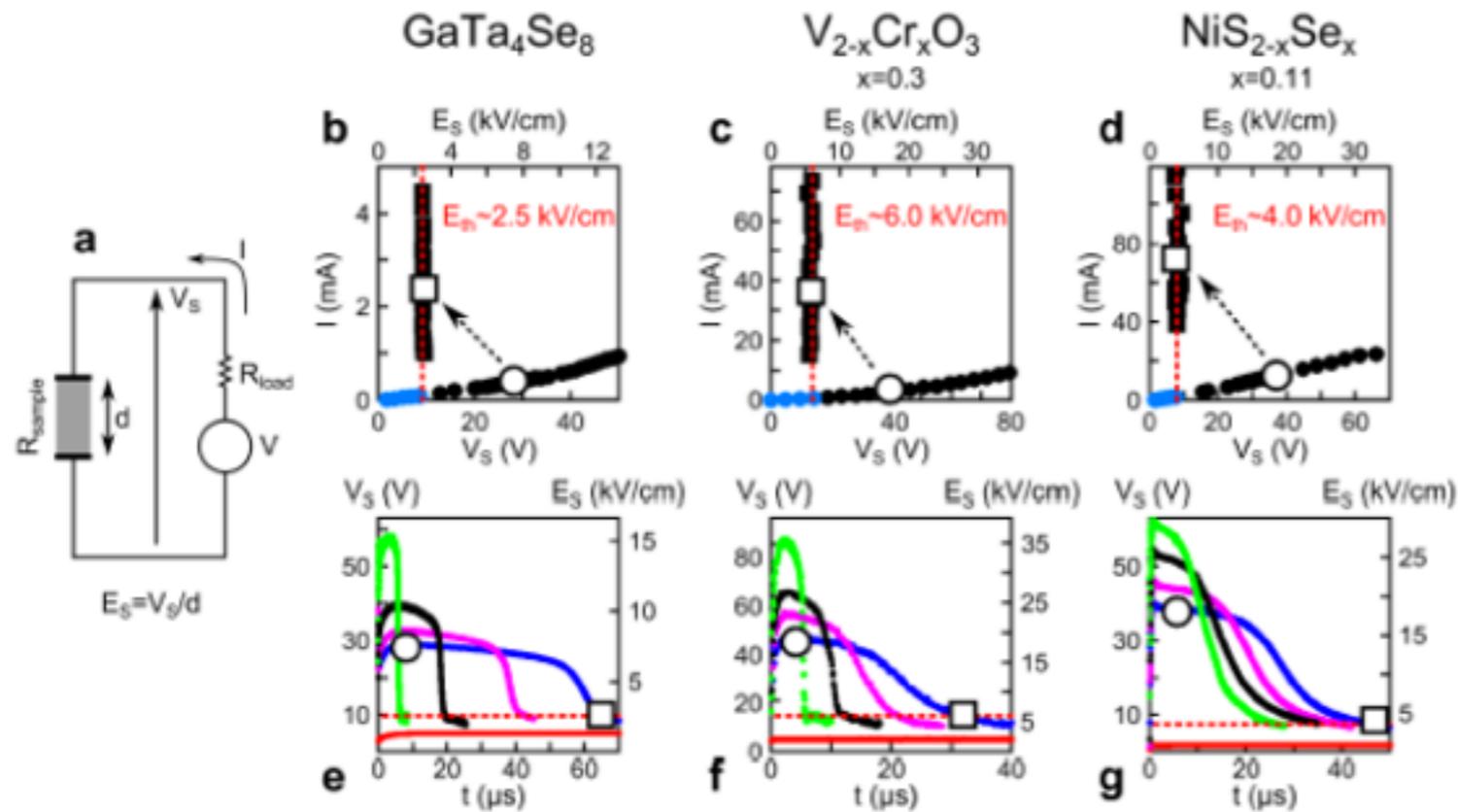
Unlock a huge number of frozen carriers

Huge potential for Mott based microelectronic devices!

Inoue & Rozenberg Adv. Funct. Mater. '08  
Janod et al Adv. Funct. Mater. '15,

# Insulators-to-Metal switch in correlated insulators

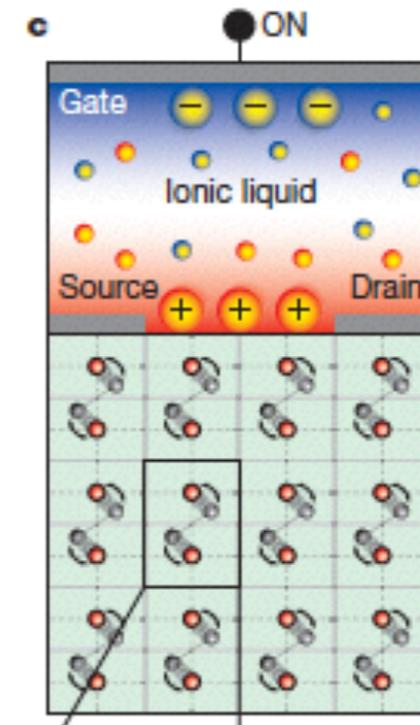
## Resistive switch experiments



Abrupt switch at fields much smaller than the gap

Guiot et al NatComm '13  
Stoilar et al AdvMat '13

## Electric-Double-Layer-Transistor



$\text{VO}_2$

bulk delocalisation above the electrostatic screening length

Nakano et al Nature '12

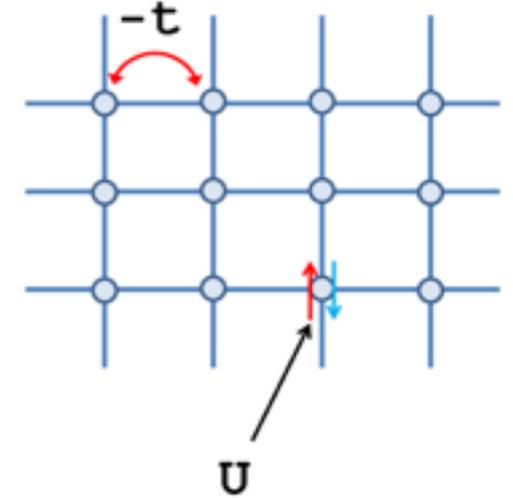
**Insulators-to-metal switch beyond semiconductor physics**

# Breakdown in Mott-Hubbard Insulators

Simplest description of a correlated insulator

dielectric breakdown

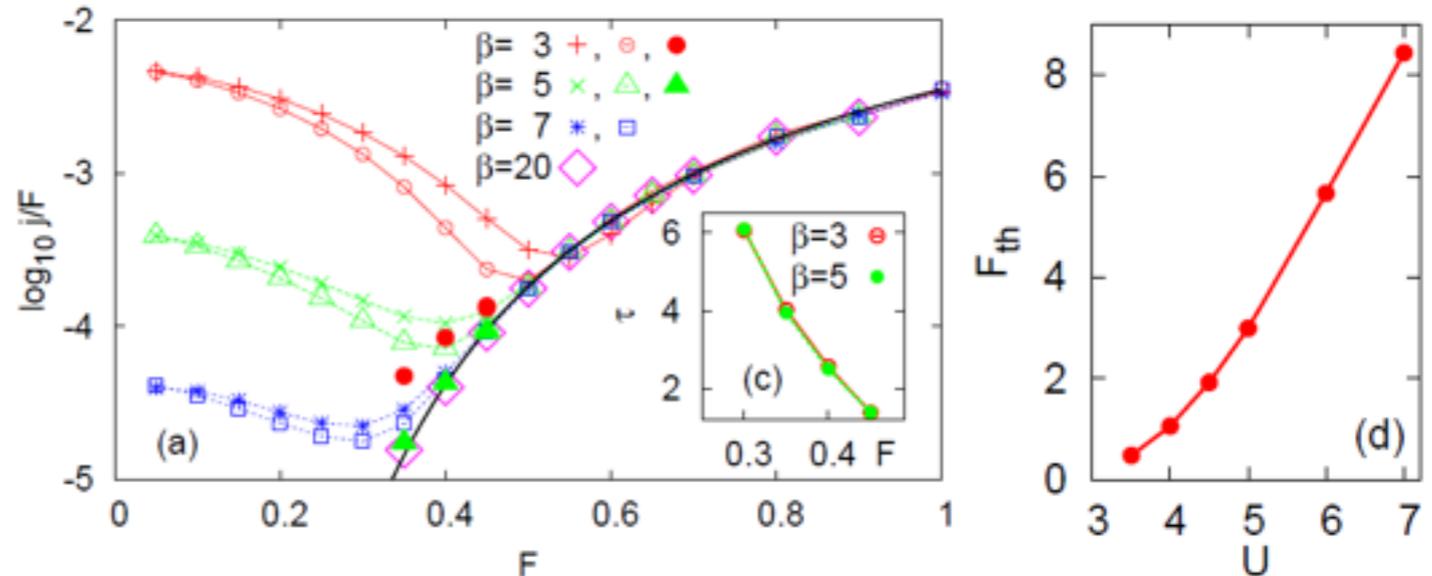
not too different from semiconductors!



\* Tunnel across the Mott-Hubbard gap

- T. Oka et al PRL '03
- S. Okamoto PRB '08
- M. Eckstein et al PRL '10
- M. Eckstein et al. PRB '14
- G. Mazza et al. PRB'15

Eckstein et al PRL 105, 146404

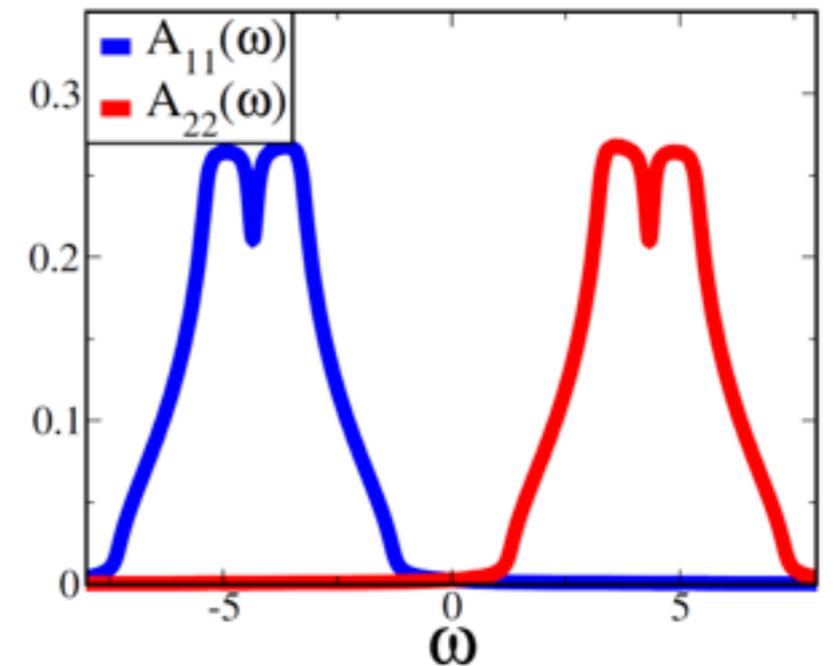
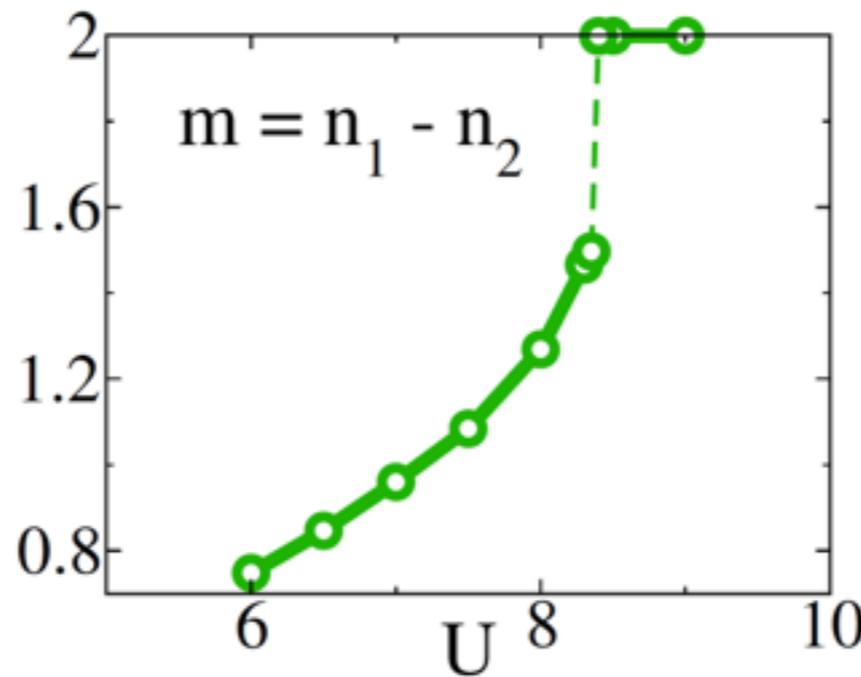
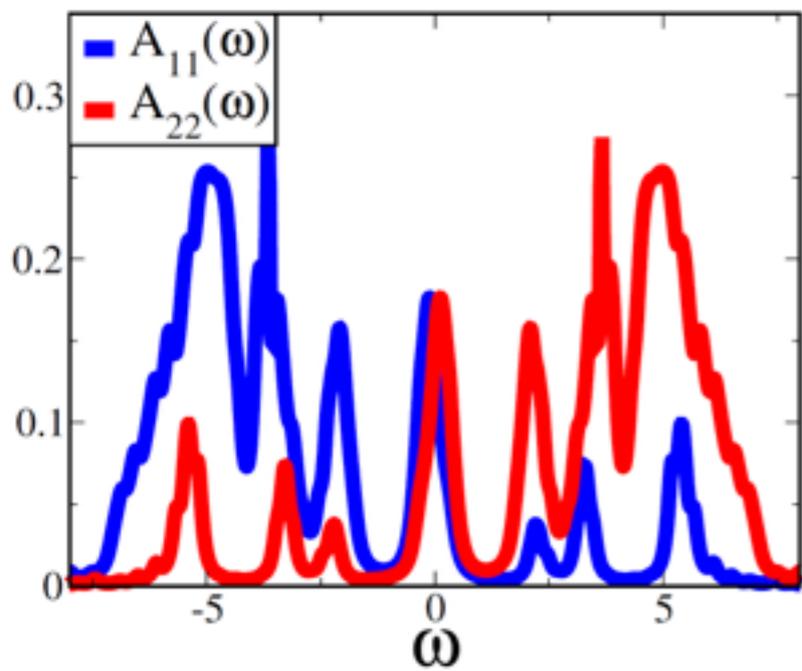
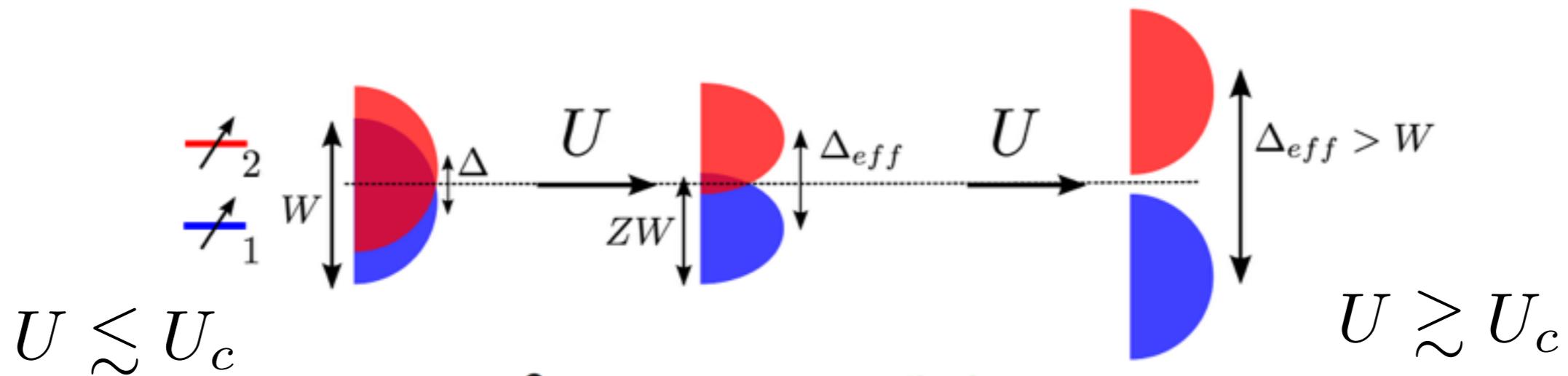


**Possible alternative route to the dielectric breakdown**

**Mott insulator coexisting with a metastable metal**

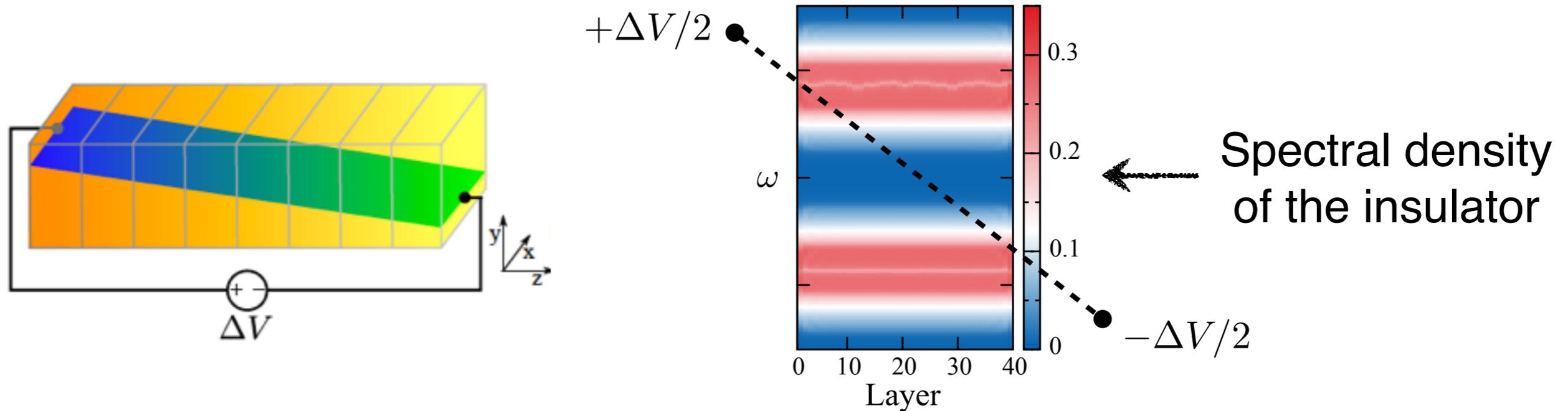
# Model: Two bands + crystal field + U

Effects of e-e correlation  $\rightarrow$  Shrinking coherent quasiparticles  $W \rightarrow ZW$   
 $\rightarrow$  Enhancement of the crystal field  $\Delta \rightarrow \Delta + Um$

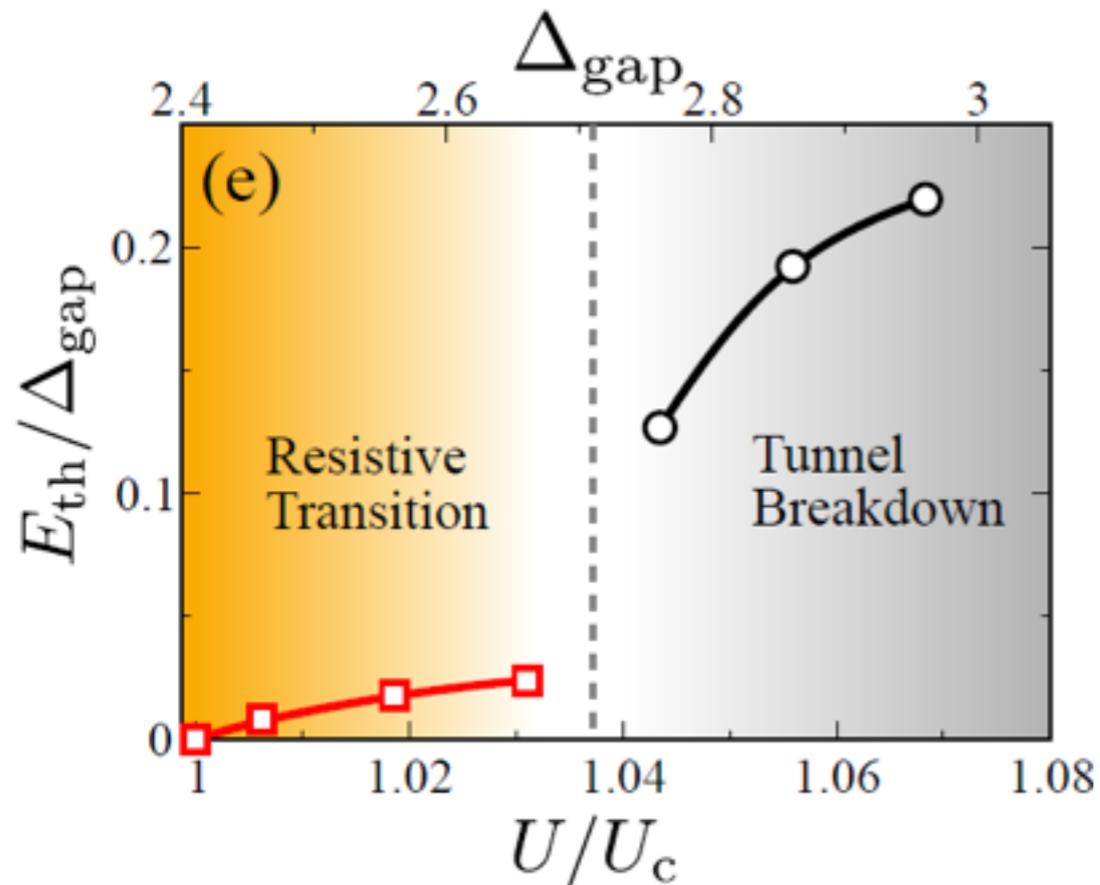


**First-order MIT (DMFT)**  
**Metal-Insulator Coexistence**

# Insulating slab w/ applied electric field



Ground state evolution across the field driven insulator-to-metal transition (real space DMFT)



**Different mechanisms  
IN and OUT  
the metal-insulator  
coexistence region!**

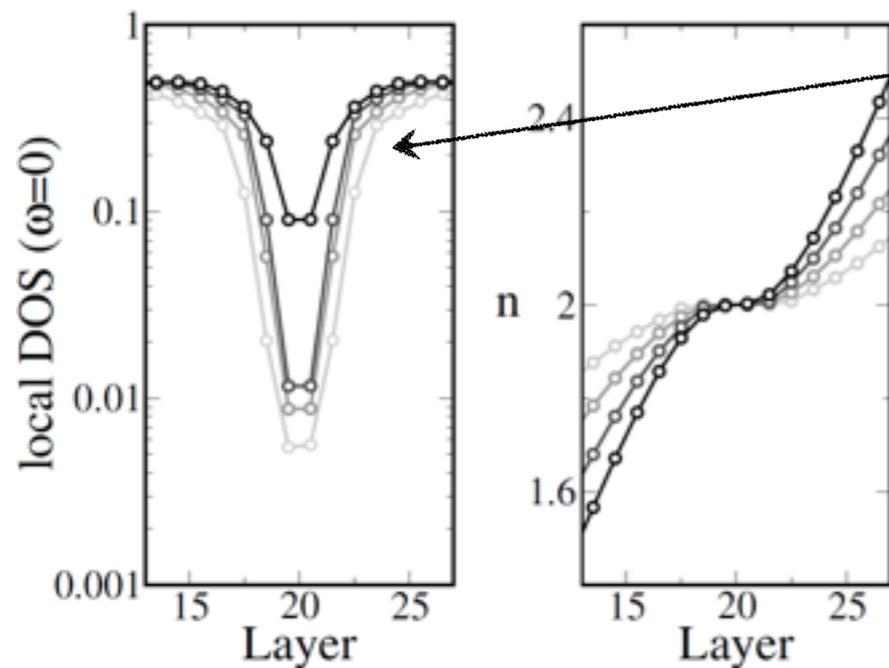
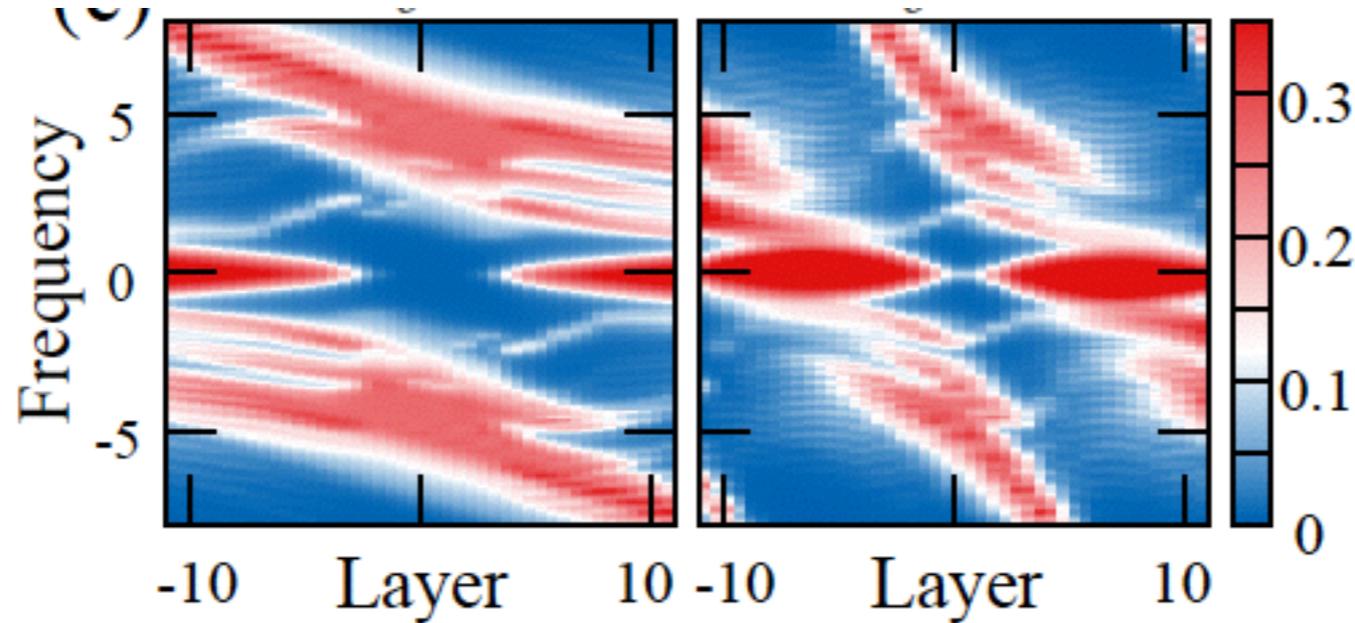
# Field-induced insulator-to-metal transition

$$U \gg U_c$$

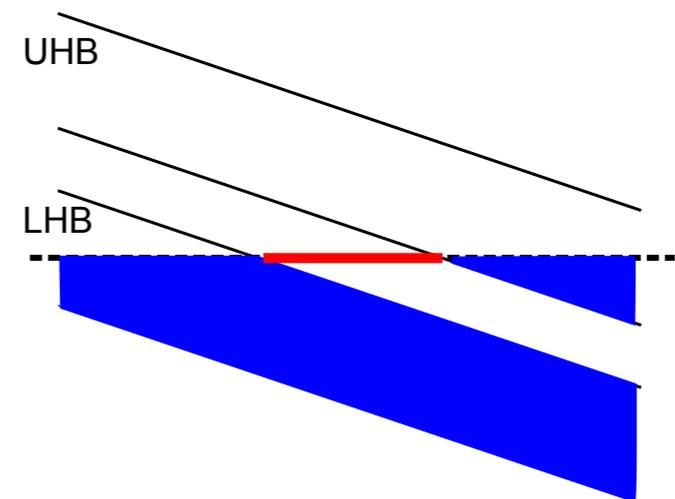
increasing Electric Field



Rigid tilt of the insulating gap



- \* inhomogeneous metal
- \* charge redistribution



“equilibrium picture” of tunnel-like conductive channel

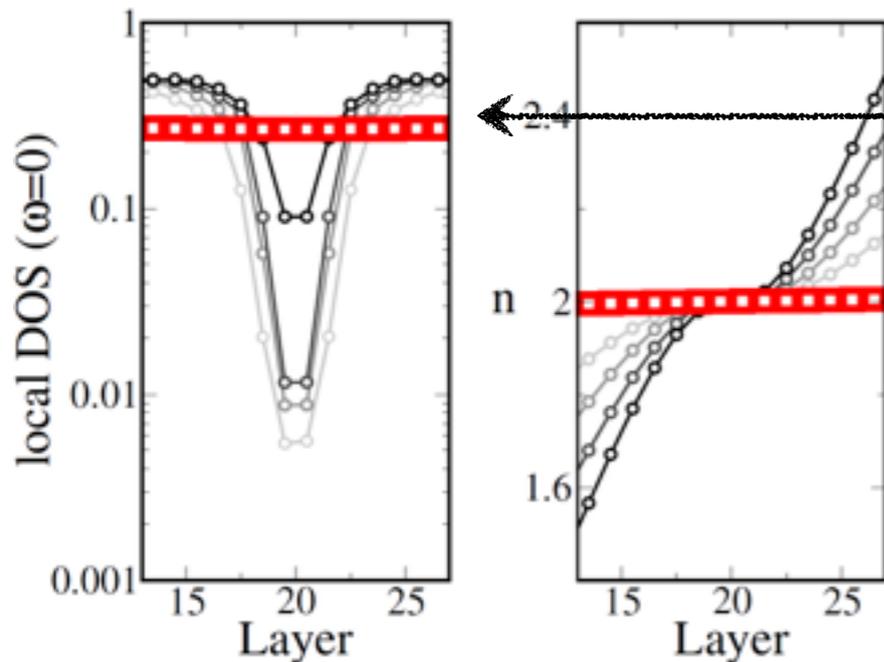
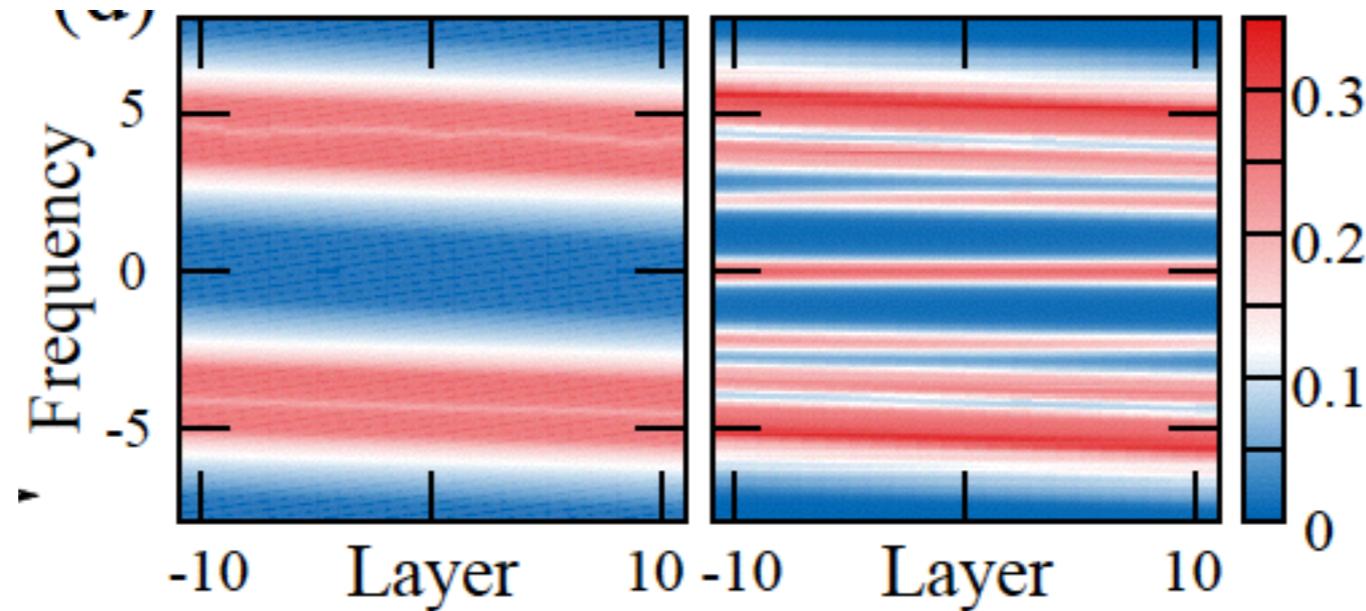
# Field-induced insulator-to-metal transition

$$U \gtrsim U_c$$

*increasing Electric Field*



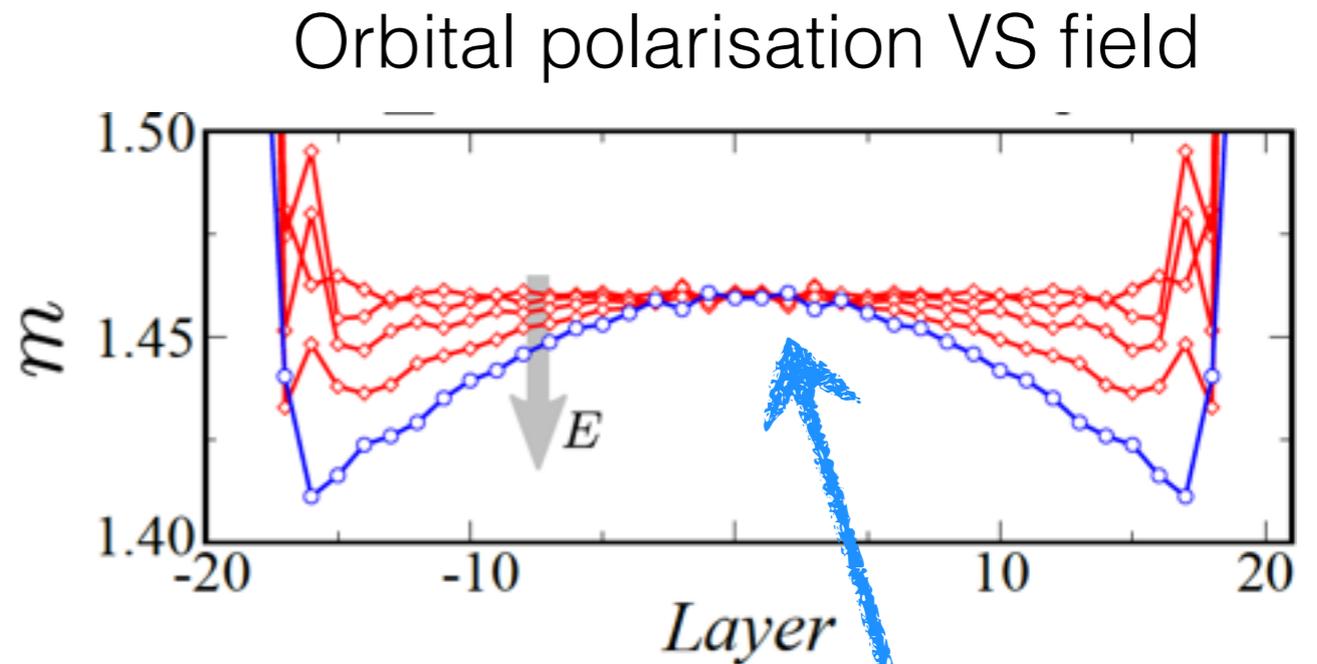
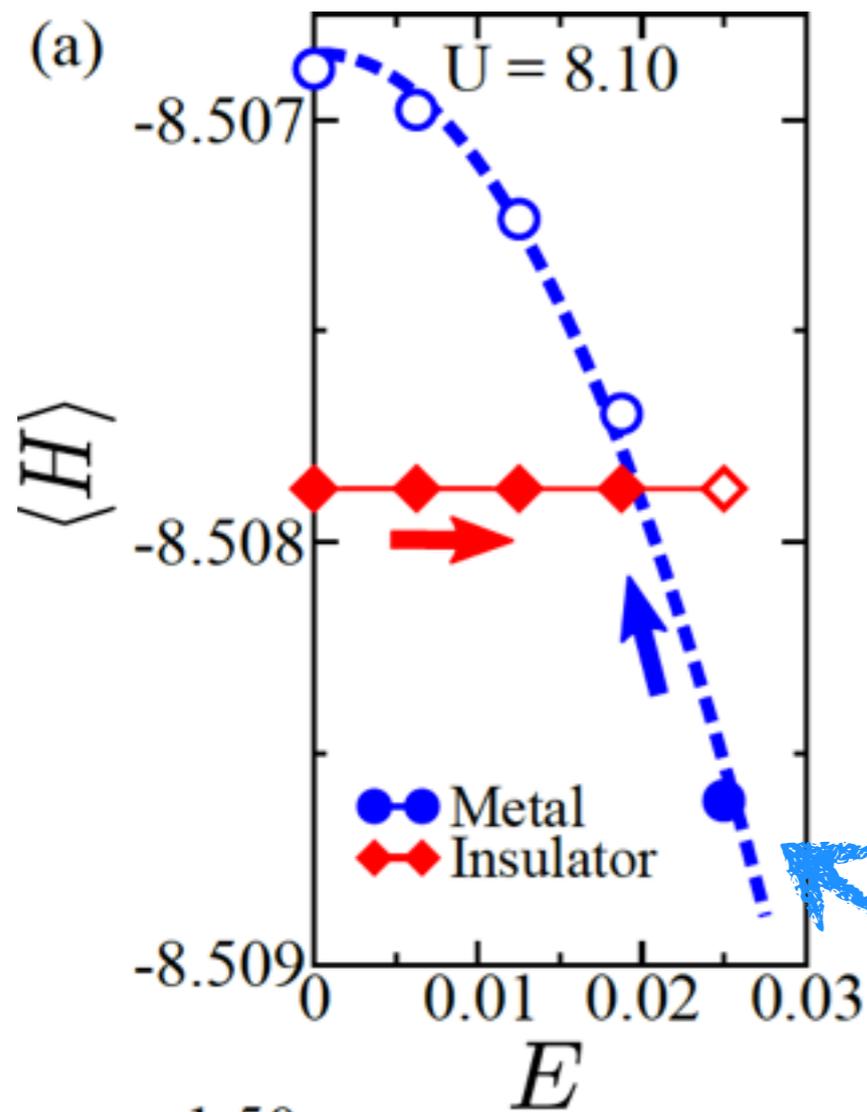
Abrupt closing  
of the gap



- \* Homogenous conductive states
- \* No charge redistribution

**First-order  
insulator-to-metal transition!**

# INS-MET hysteresis loop VS electric field



The electric field reduces the effect of correlations

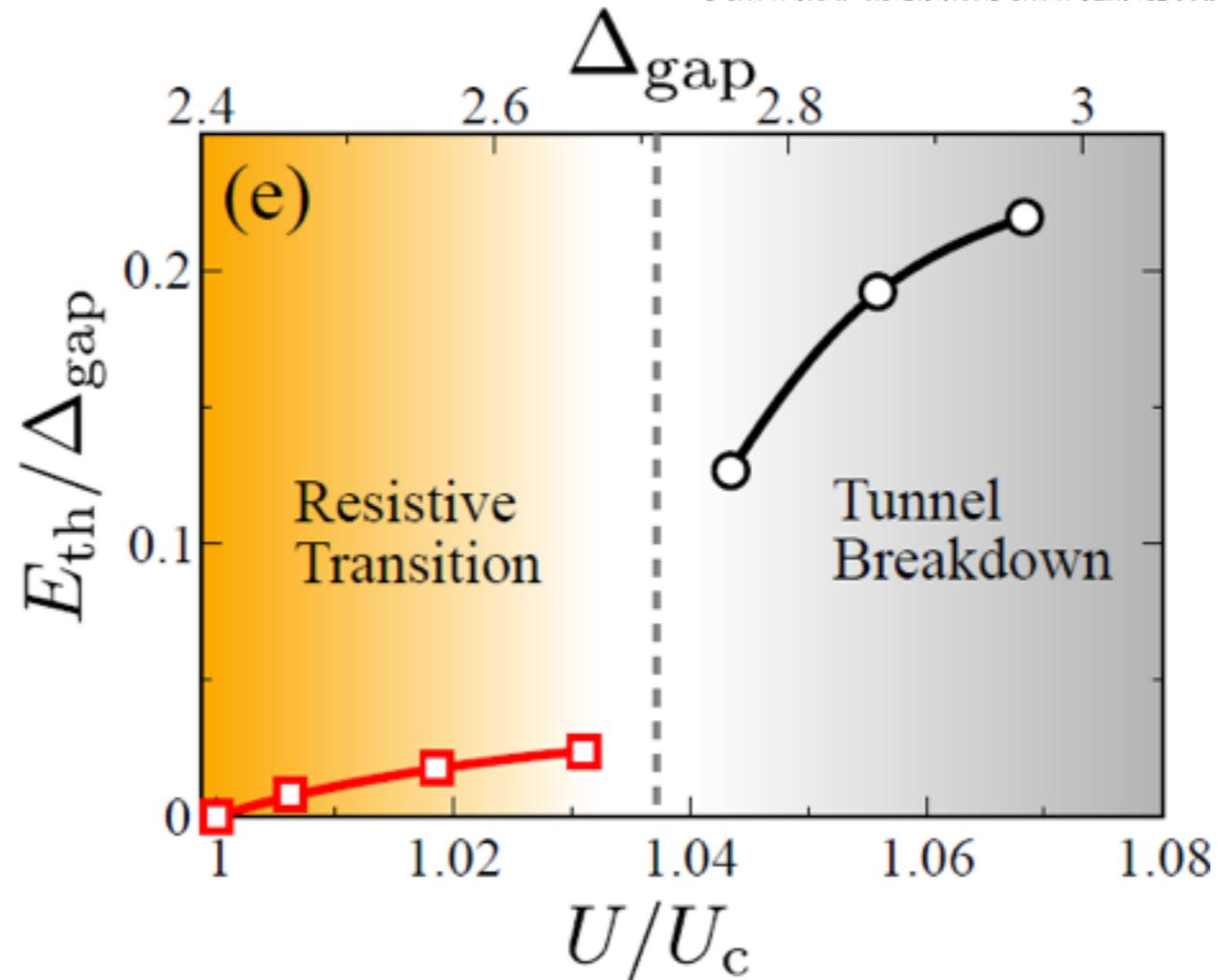
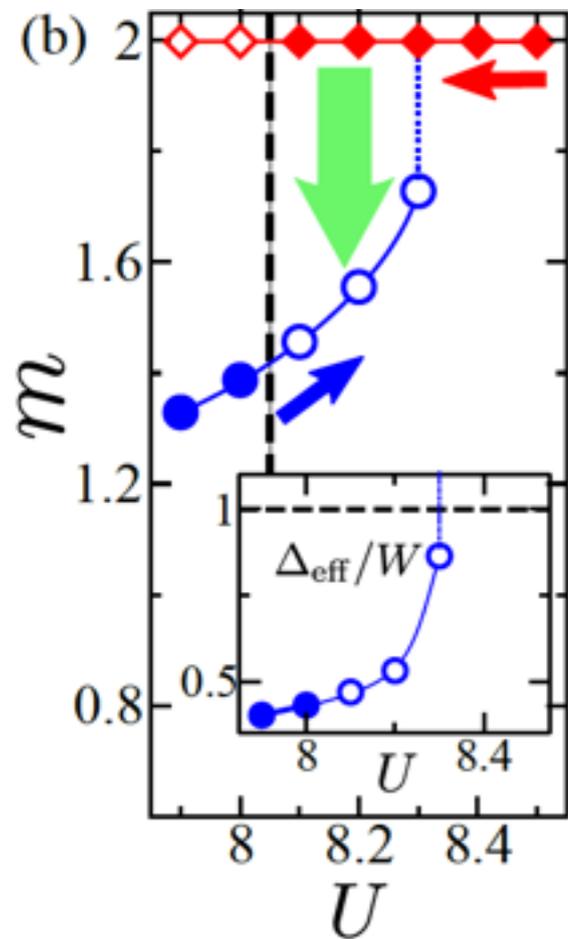
Energy gain within the linear response regime

$$\delta \langle H \rangle \propto E^2$$

**Relatively small electric field is able to induce the switch between the two competing phases!**

# Different routes for the Mott insulator metallisation

Rigid modification of the insulator (only one stable phase)

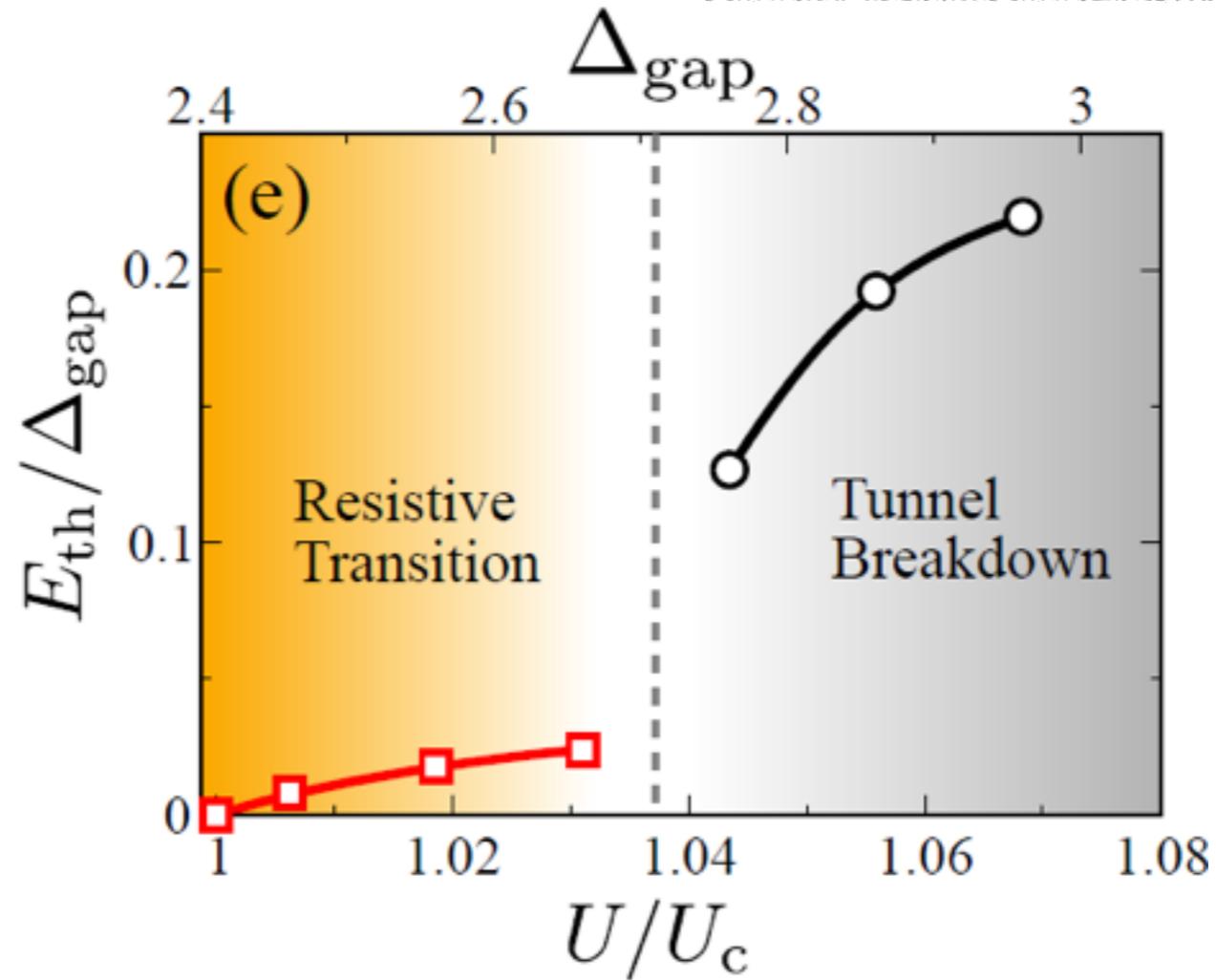
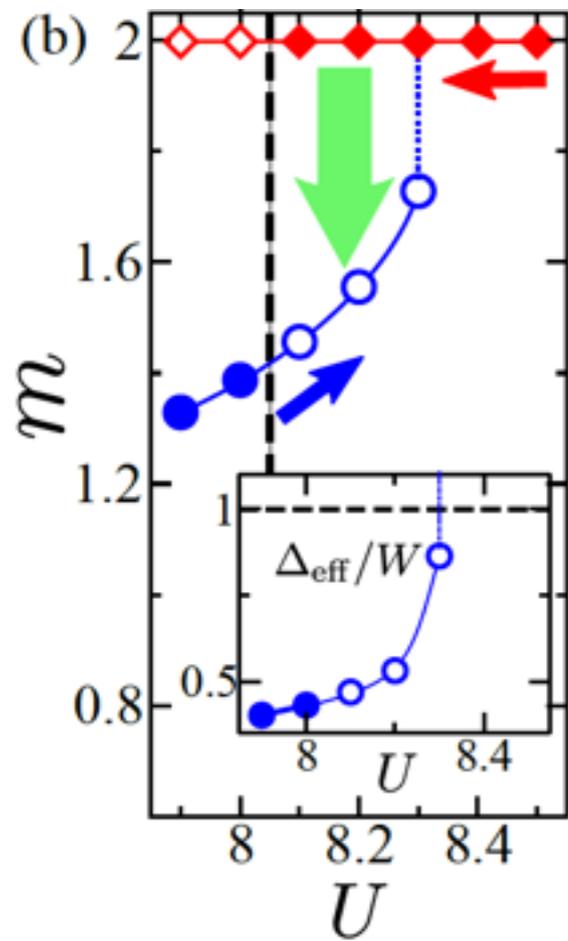


Switch between two competing phases

**Qualitative and quantitative different IMT!**

# Different routes for the Mott insulator metallisation

Rigid modification of the insulator (only one stable phase)



Switch between two competing phases

**Qualitative and quantitative different IMT!**

Thank you